


# Manganese iridium

Product	Manganese iridium (sputtering target)
Manufacturer	ACI Alloys Inc.
Composition	80% manganese, 20% iridium; solid
Synonyms	MnIr
Typical Uses	Thin-film material deposited via sputtering.
Hazards	<div> 000 Specific target organ toxicity – repeated exposure <span>CATEGORY 2</span></div>
Storage	Precious metals target cabinet.
Disposal	Collected for precious metals reclamation.
Comments	Avoid dust formation. Avoid breathing dust. Wear gloves when handling. Approved for sputtering in <i>Sputtering System #4 (Moe)</i> .
Status	<span>RESTRICTED USE</span>



**Check First**

Please contact a nanoFAB staff member for uses not listed above.